

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)
)
Osamu Nozawa et al.)
)
Serial No.: 10/771,997)
)
Filed: February 4, 2004)
)
For: Manufacturing Method And Apparatus of)
Phase Mask Shift Blank)
)
Examiner: Rodney Glenn McDonald)
)
Confirmation No.: 4072)
)
Art Unit: 1795)

AMENDMENT H

Commissioner of Patents
P. O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Applicants have the following response to the Office Action December 27, 2007, a one month extension of time having been submitted on March 25, 2008.

Please amend the above-identified application as follows: